



PRESS RELEASE

January 2010 – Waterborne Inks and Coatings:

ESP is pleased to announce the launch of new, highly-potent siloxane supported foam control technology that exhibits outstanding compatibility and print characteristics. With the introduction of FC 2-006-24 and FC 2-014-31, ESP ushers in a new opportunity for increased customer press speeds by eliminating the typical accompanying foam buildup without sacrificing print quality.

These defoamer chemistries have shown outstanding foam control initially and especially after aging in controlled and variable-temperature environments such as warehouse storage. Print quality and solution stability are outstanding, as these defoamers have very little impact on actual surface tension. As a result they offer smooth, defect-free film characteristics. These characteristics combine with their foam control properties to make them extremely effective foam control options for a wide range of systems, especially those oriented to highly defect-sensitive substrates and/or demanding press configurations.

About Enterprise Specialty Products:

Enterprise Specialty Products (ESP) is a leading manufacturer and supplier of antifoams to the wastewater treatment marketplace. As one of our core markets, ESP has extensive experience across all facets of wastewater processes, within both industrial and municipal settings. ESP services the foam control needs of the industrial marketplace as well, with leading-edge technology in silicone, synthetic, and oilbased antifoam/defoamer additives for a diverse range of industries including: graphics, metalworking, adhesives, nonwovens, emulsion polymer, textile, paper, paint, construction chemicals, mining, oilfield, and specialty chemicals. With over 100 years of collective experience, our technical staff applies their direct backgrounds in our target markets to provide real-world support for our customers. ESP is focused on customer service, and we emphasize building partnerships with our customers to provide solutions to their foaming challenges.